

## Electronic Supplementary Information

### One-step femtosecond laser patterning of light-trapping structure on dye-sensitized solar cell photoelectrode

5

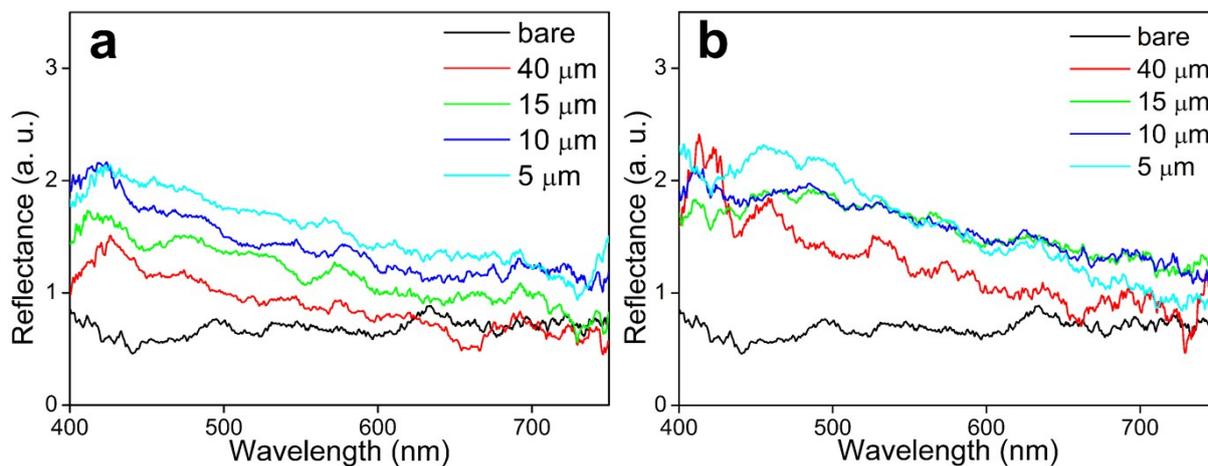
*Xi Zhang, Hwei Liu, Xuezhen Huang, and Hongrui Jiang\**

[\*] Prof. H. Jiang, Dr. X. Zhang, Dr. H. Liu, Dr. X. Huang  
Materials Science Program, Department of Electrical and Computer Engineering

10 University of Wisconsin-Madison

Madison, WI 53706 (USA)

E-mail: [hongruijiang@wisc.edu](mailto:hongruijiang@wisc.edu)

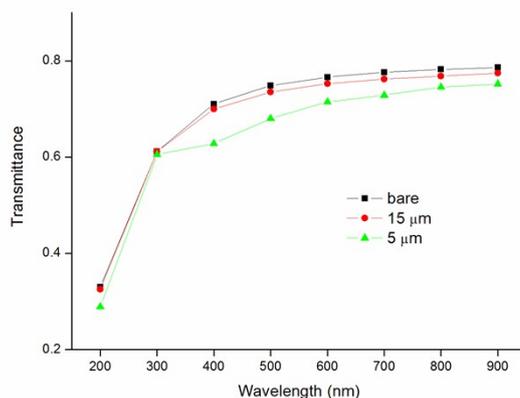


15

**Figure S1** Reflectance spectra of nanostructured TiO<sub>2</sub> films before and after laser ablation. (a) Results of bare and grating-patterned TiO<sub>2</sub>; (b) results of bare and orthogonal-grid-patterned TiO<sub>2</sub>. The grid spacing of both types of patterns on the ablated photoelectrodes ranges from 5 μm to 40 μm.

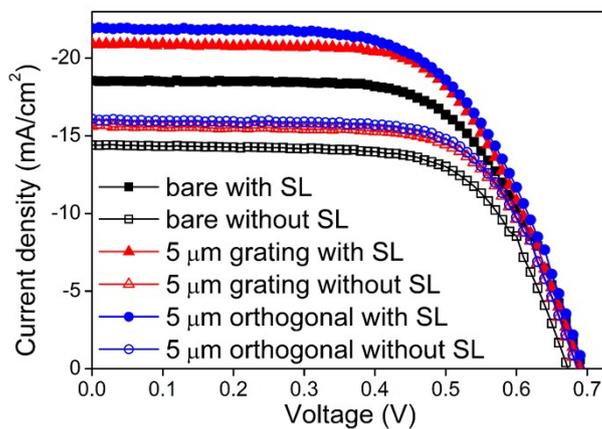
20

25



**Figure S2** Simulated transmittance spectra of nanostructured TiO<sub>2</sub> films before and after laser ablation with orthogonal-grid patterns. The results of 5- $\mu\text{m}$  and 15- $\mu\text{m}$  grid spacings are shown.

5



**Figure S3**  $J$ - $V$  curves of DSSCs with and without scattering layer (SL). The results of DSSCs with 10 bare, 5- $\mu\text{m}$  grating-patterned and 5- $\mu\text{m}$  orthogonal-grid-patterned TiO<sub>2</sub> photoelectrodes are shown. The thickness of the photoelectrode without SL is 10  $\mu\text{m}$ .

**Table S1** Amount of adsorbed dye on each TiO<sub>2</sub> photoelectrode (all with SL).

Pattern	amount of adsorbed dye (10 <sup>-7</sup> mol/cm <sup>2</sup> )	$J_{sc}$ (mA/cm <sup>2</sup> )	$\eta$ (%)
bare	1.53	18.6	8.21
40 $\mu$ m grating	1.30	20.2	8.61
15 $\mu$ m grating	1.36	20.6	8.73
10 $\mu$ m grating	1.34	20.5	8.88
5 $\mu$ m grating	1.29	20.9	9.14
40 $\mu$ m orthogonal	1.30	20.9	9.16
15 $\mu$ m orthogonal	1.32	21.9	9.18
10 $\mu$ m orthogonal	1.40	21.6	9.23
5 $\mu$ m orthogonal	1.35	21.9	9.32

**5 Table S2**  $J$ - $V$  parameters of DSSCs with and without SL corresponding to the curves in Fig. S3.

TiO <sub>2</sub> Photoelectrode	$V_{oc}$ (V)	$J_{sc}$ (mA/cm <sup>2</sup> )	FF (%)	$\eta$ (%)
bare with SL	0.70	18.6	63.2	8.21
bare without SL	0.68	14.4	66.5	6.51
5 $\mu$ m grating with SL	0.70	20.9	62.4	9.14
5 $\mu$ m grating without SL	0.69	15.6	67.5	7.29
5 $\mu$ m orthogonal with SL	0.70	21.9	60.7	9.32
5 $\mu$ m orthogonal without SL	0.69	16.1	67.1	7.45